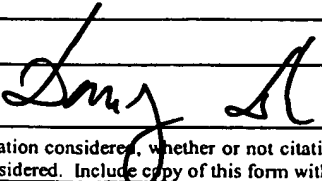
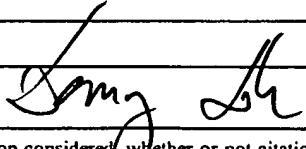
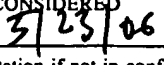


Form PTO-1449 (REV. 1/06)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 118118		APPLICATION NO. 10/736,644	
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)				APPLICANT(S) Hiroyuki OGI			
				FILING DATE December 17, 2003		GROUP 2834	
U.S. PATENT DOCUMENTS							
Examiner Initials	Cite No.	Document Number	Date	Name			
K	1	5,949,166	9/1999	Ooiwa et al.			
FOREIGN PATENT DOCUMENTS							
Examiner Initials	Cite No.	Document Number	Date	Country	With English Abstract	With English Translation	
	2	CN 1173738	2/1998	China			
	3	CN 1084876	5/2002	China			
OTHER DOCUMENTS							
Examiner Initials	Cite No.	(Including Author, Title, Date, Pertinent Pages, etc.)					
EXAMINER						DATE CONSIDERED 5/23/06	
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Date: March 21, 2006

Form PTO-1449 (REV. 1/06)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 118118		APPLICATION NO. 10/736,644	
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)				APPLICANT(S) Hiroyuki OGI FILING DATE December 17, 2003			
U.S. PATENT DOCUMENTS							
Examiner Initials	Cite No.	Document Number	Date	Name			
DL	1	3,078,409	2/1963	Bertsche, Jr. et al.			
DL	2	4,554,574	11/1985	Wright			
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Examiner Initials	Cite No.	Document Number	Date	Country	With English Abstract	With English Translation	
DL	4	2 057 763 A	4/1981	Great Britain			
OTHER DOCUMENTS							
Examiner Initials	Cite No.	(Including Author, Title, Date, Pertinent Pages, etc.)					
EXAMINER				DATE CONSIDERED			
							
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Date: February 10, 2006